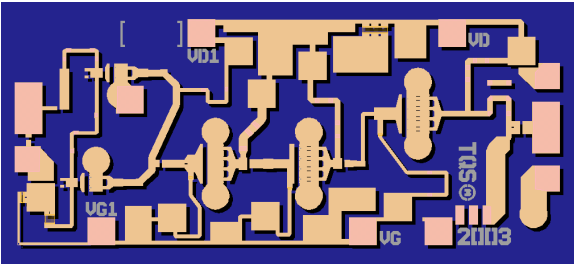


19 - 38 GHz Medium Power Amplifier



Key Features

- Frequency Range: 19 - 38 GHz
- 20 dB Nominal Gain
- 22 dBm Nominal Psat
- 30 dBm Nominal TOI
- Bias: 5 V, 160 mA (210mA @ P1dB)
- 0.25 um 3MI pHEMT Technology
- Chip Dimensions 1.69 x 0.75 x 0.10 mm (0.066 x 0.030 x 0.004 in)

Product Description

The TriQuint TGA4036 is a compact Medium Power Amplifier MMIC for Wide-band applications. The part is designed using TriQuint's proven standard 0.25 um power pHEMT production process.

The TGA4036 provides a nominal 20 dB Gain from 19-36 GHz, with Saturated Output Power of 22 dBm.

The part is ideally suited for low cost emerging markets such as Point-to-Point Radio, Point-to-Multi Point Communications, and Instrumentation.

The TGA4036 is 100% DC and RF tested on-wafer to ensure performance compliance.

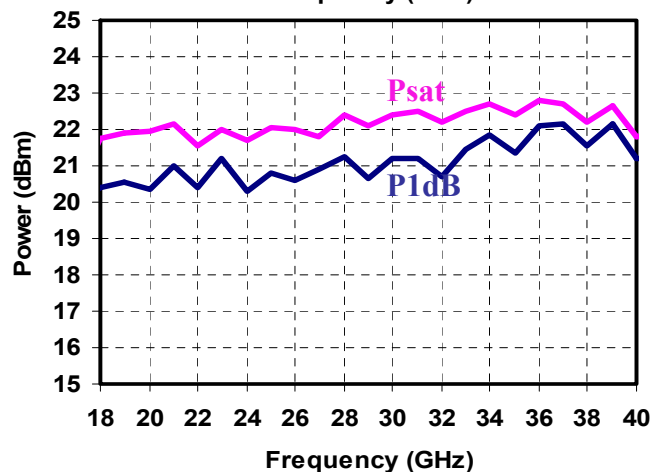
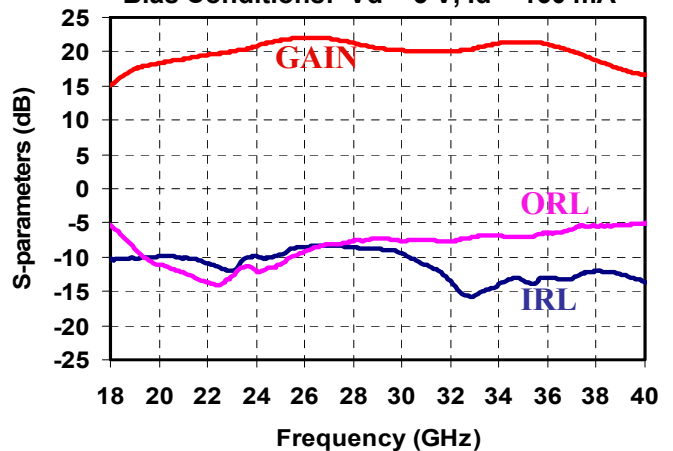
Evaluation boards are available.

Primary Applications

- Point-to-Point Radio
- Point-to-Multipoint Communications
- Instrumentation

Measured Fixtured Data

Bias Conditions: $V_d = 5\text{ V}$, $I_d = 160\text{ mA}$



Datasheet subject to change without notice

TABLE I
MAXIMUM RATINGS 1/

SYMBOL	PARAMETER	VALUE	NOTES
V _d	Drain Voltage	7 V	<u>2/</u>
V _g	Gate Voltage Range	-1 TO +0.5 V	
I _d	Drain Current	400 mA	<u>2/</u> <u>3/</u>
I _g	Gate Current	7 mA	<u>3/</u>
P _{IN}	Input Continuous Wave Power	20 dBm	
P _D	Power Dissipation	2.5 W	<u>2/</u> <u>4/</u>
T _{CH}	Operating Channel Temperature	200 °C	<u>5/</u> <u>6/</u>
	Mounting Temperature (30 Seconds)	320 °C	
T _{STG}	Storage Temperature	-65 to 150 °C	

- 1/ These ratings represent the maximum operable values for this device.
- 2/ Combinations of supply voltage, supply current, input power, and output power shall not exceed P_D.
- 3/ Total current for the entire MMIC.
- 4/ When operated at this bias condition with a base plate temperature of 70 °C, the median life is 2.3E4 hrs.
- 5/ Junction operating temperature will directly affect the device median time to failure (T_m). For maximum life, it is recommended that junction temperatures be maintained at the lowest possible levels.
- 6/ These ratings apply to each individual FET.

TABLE II
DC PROBE TEST
(T_A = 25 °C)

SYMBOL	PARAMETER	MINIMUM	MAXIMUM	UNIT
I _{dss (Q1A)}	Saturated Drain Current	15	94	mA
G _{m (Q1A)}	Transconductance	33	106	mS
V _{p (Q1)}	Pinch-off Voltage	-1.5	-0.5	V
BVGS _(Q1A)	Breakdown Voltage Gate-Source	-30	-8	V
BVGD _(Q1A,Q1B)	Breakdown Voltage Gate-Drain	-30	-10	V

Q1A and Q1B are 150um Input FETs

TABLE III
ELECTRICAL CHARACTERISTICS
 (Ta = 25 °C Nominal)

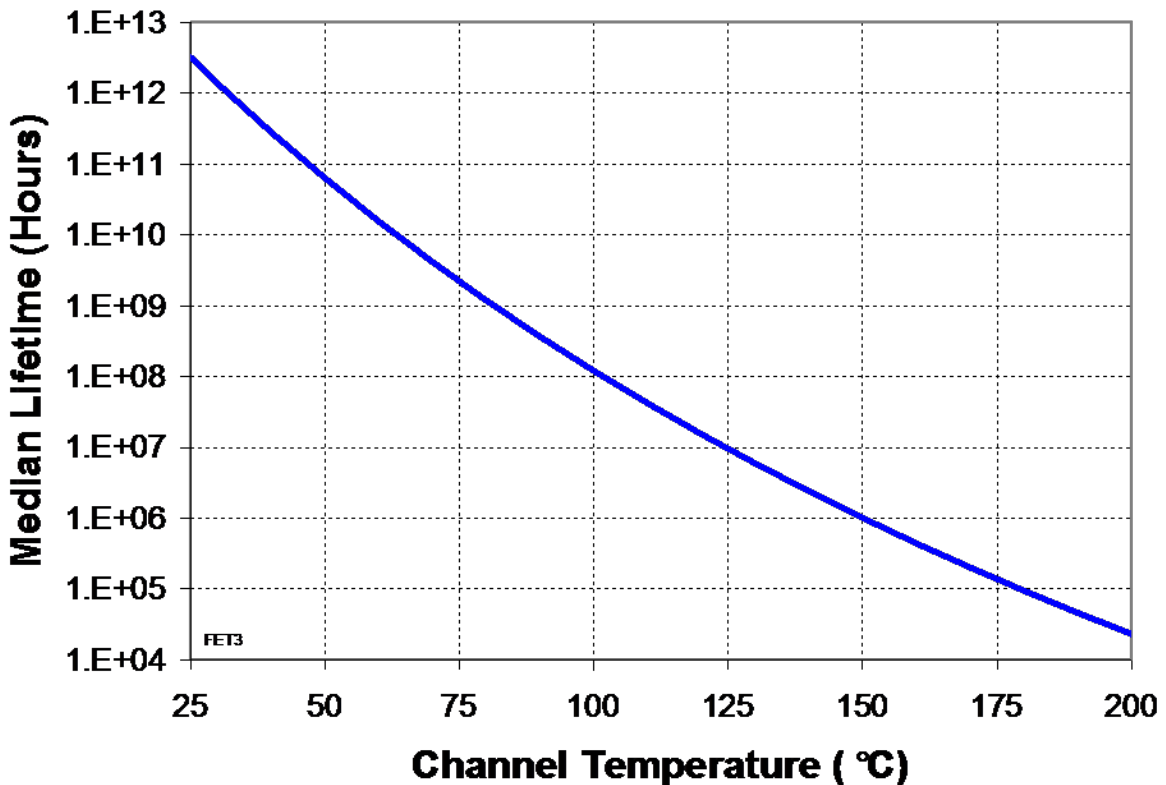
PARAMETER	TYPICAL	UNITS
Frequency Range	19 - 38	GHz
Drain Voltage, Vd	5.0	V
Drain Current, Id	160	mA
Gate Voltage, Vg	-0.6	V
Small Signal Gain, S21	20	dB
Input Return Loss, S11	11	dB
Output Return Loss, S22	8	dB
Output Power @ 1dB Gain compression, P1dB	21	dBm
Saturated Output Power, Psat	22	dBm
Output TOI @ Pin/tone = -10dBm	30	dBm
Temperature Coefficient	0.038	dB/°C

TABLE IV
THERMAL INFORMATION

PARAMETER	TEST CONDITIONS	T _{CH} (°C)	θ _{JC} (°C/W)	T _m (HRS)
θ _{JC} Thermal Resistance (channel to Case)	V _d = 5 V I _d = 160 mA P _{diss} = 0.80 W	112	51.9	3.4E+7

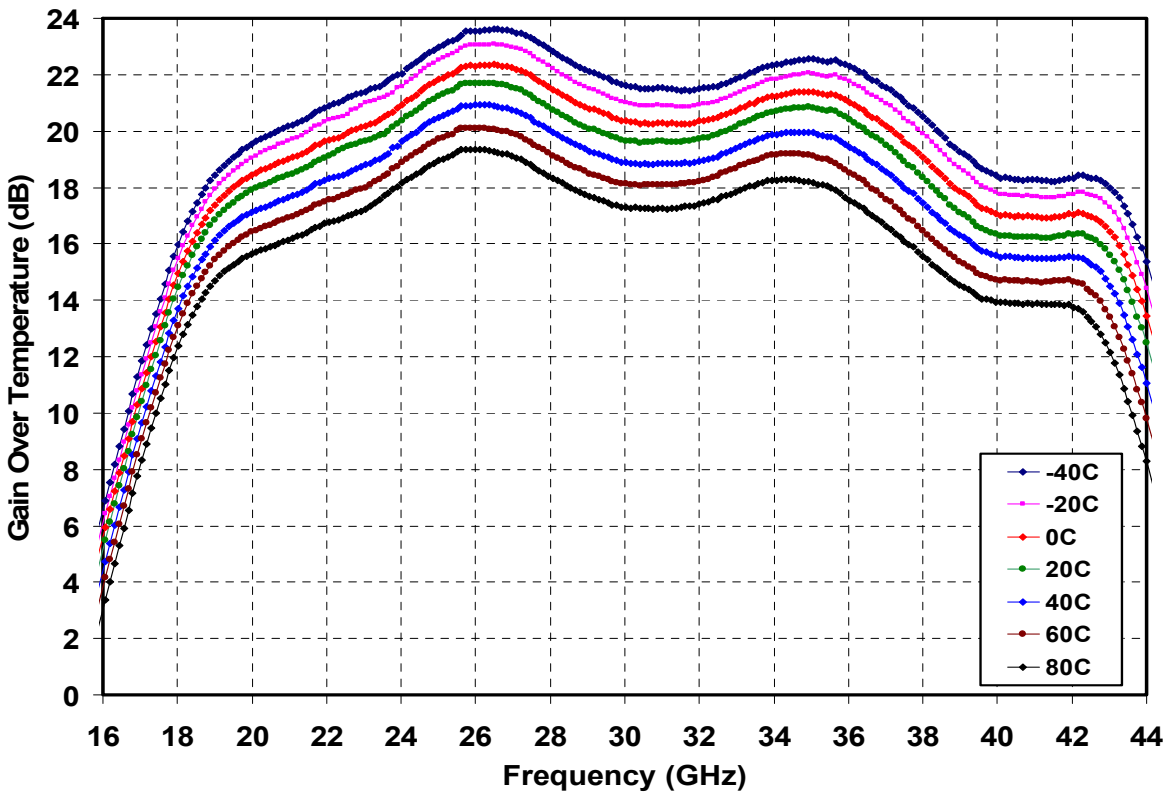
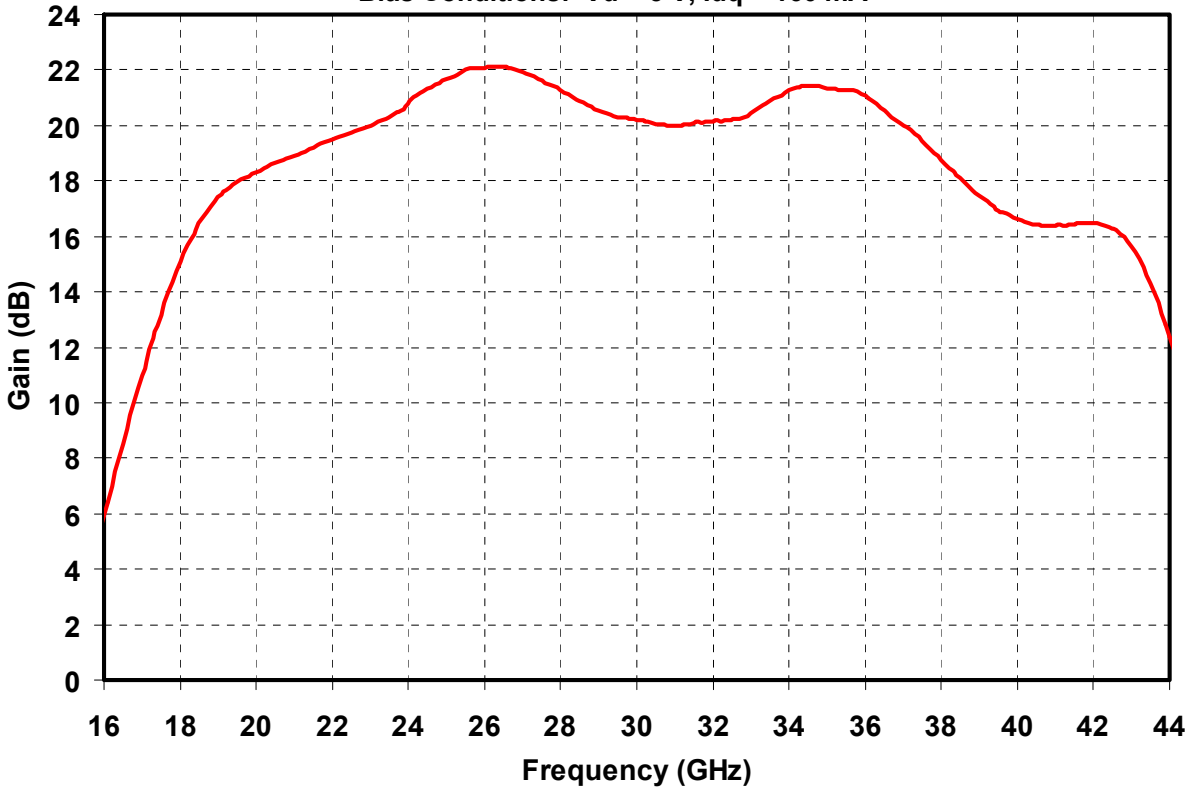
Note: Assumes eutectic attach using 1.5 mil 80/20 AuSn mounted to a 20 mil CuMo Carrier at 70 °C baseplate temperature. Worst case condition with no RF applied, 100% of DC power is dissipated.

Median Lifetime (T_m) vs. Channel Temperature



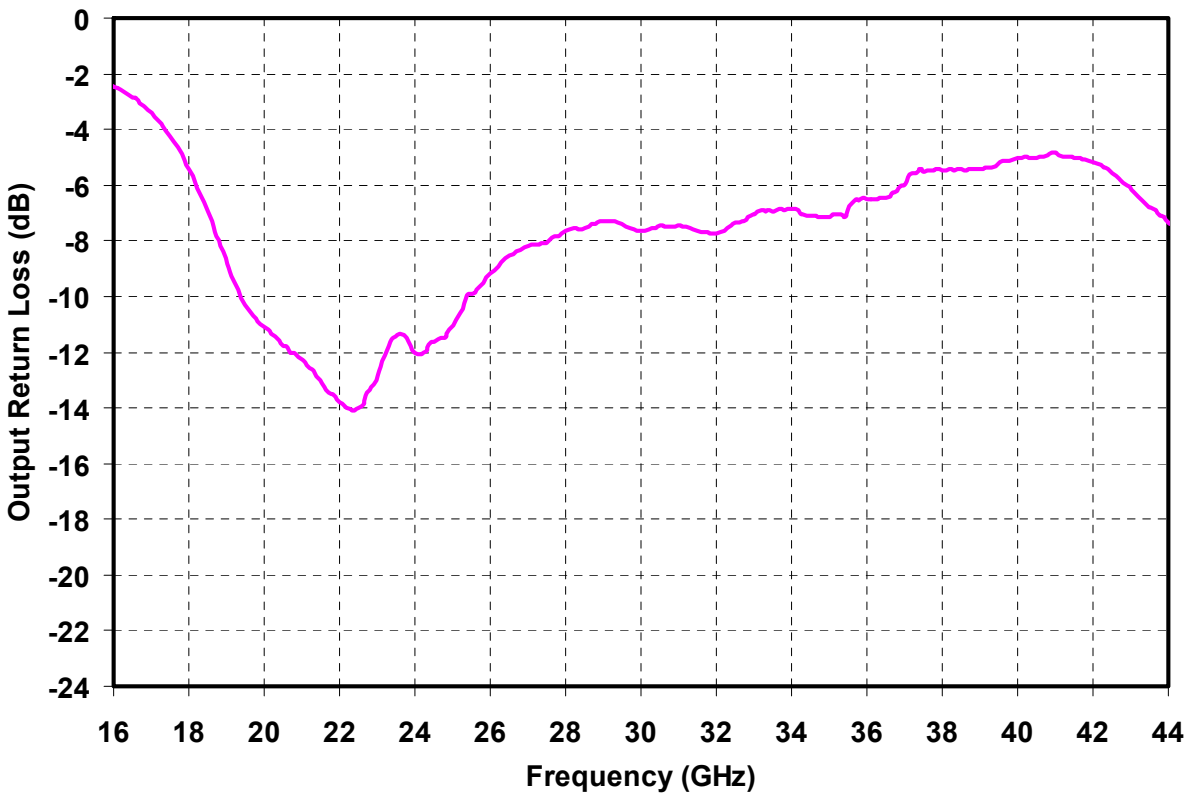
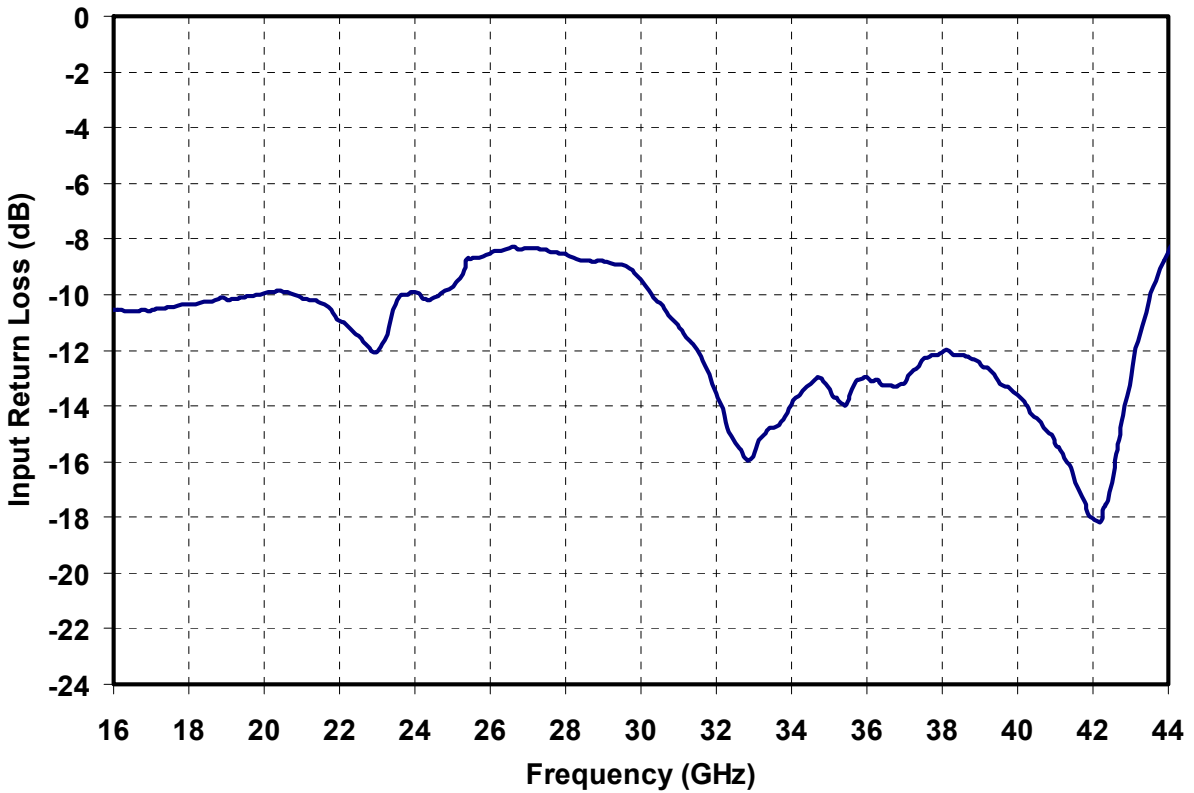
Preliminary Measured Data

Bias Conditions: $V_d = 5\text{ V}$, $I_{dq} = 160\text{ mA}$



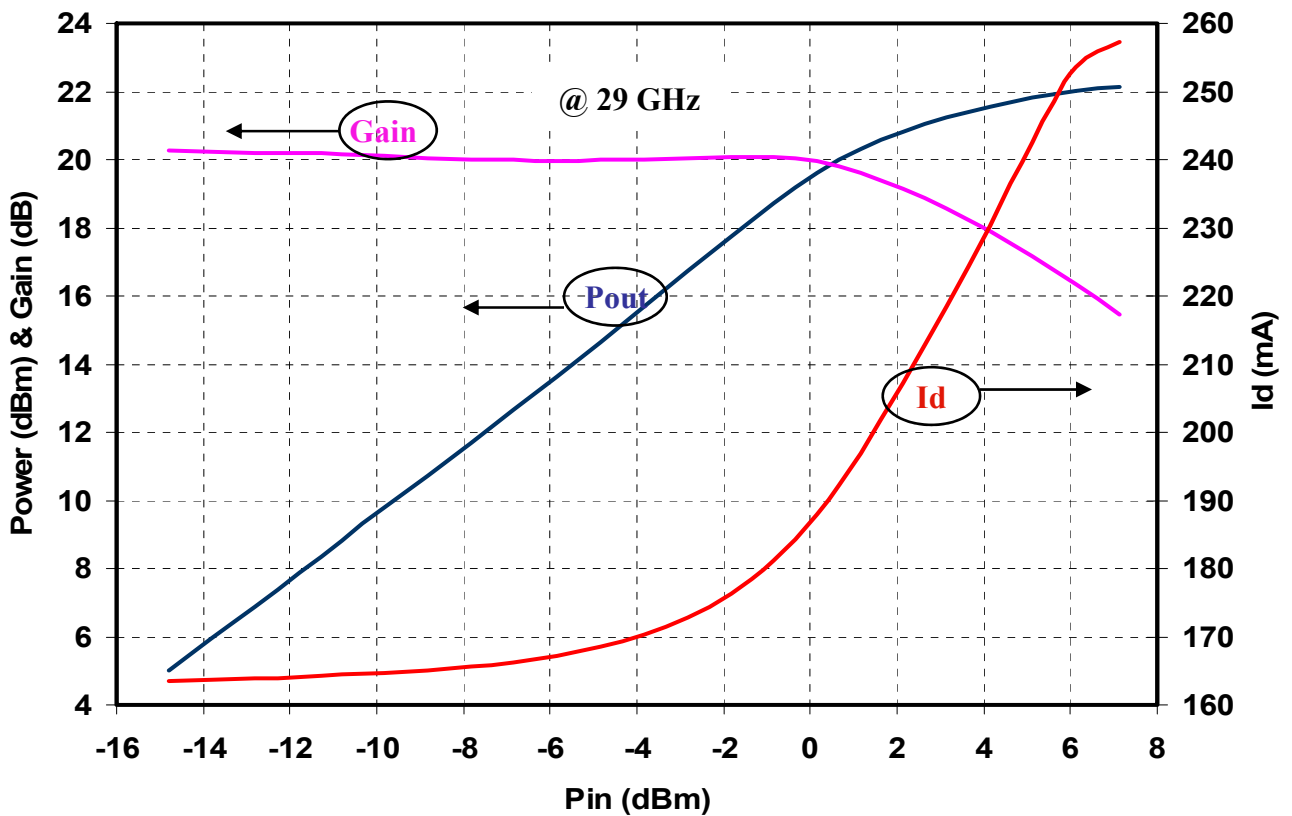
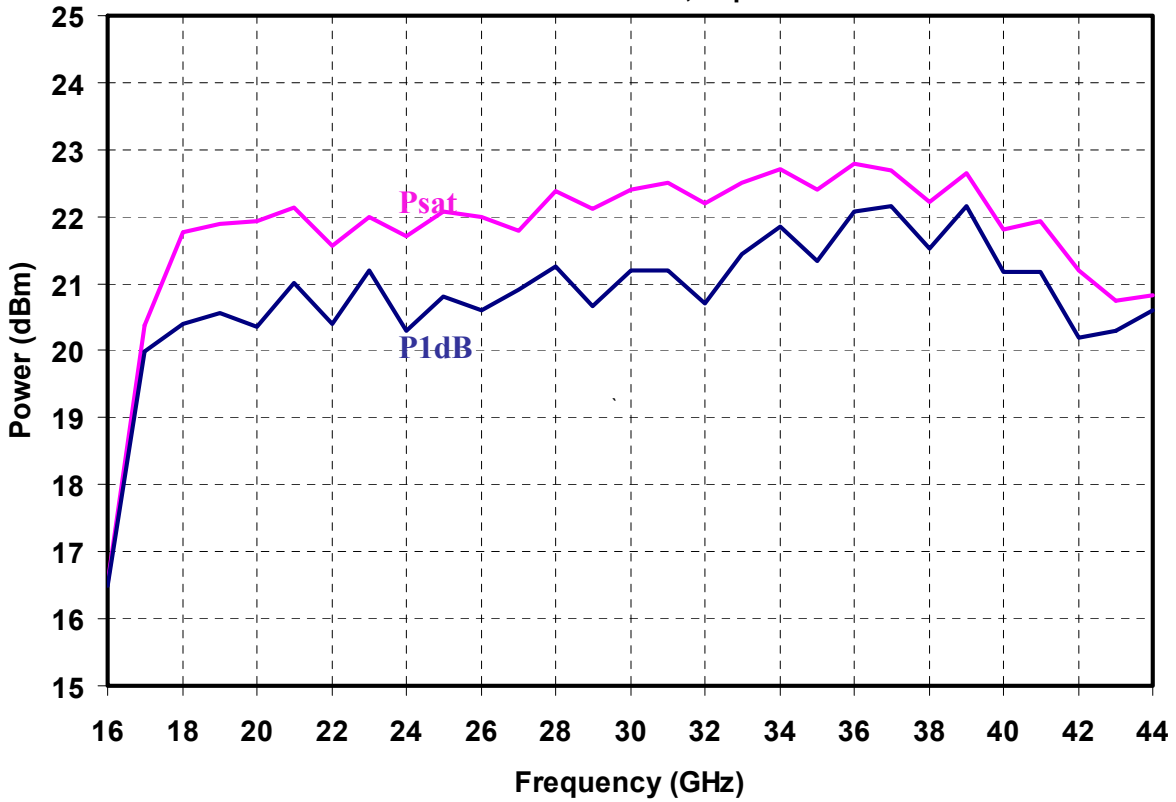
Preliminary Measured Data

Bias Conditions: $V_d = 5\text{ V}$, $I_{dq} = 160\text{ mA}$



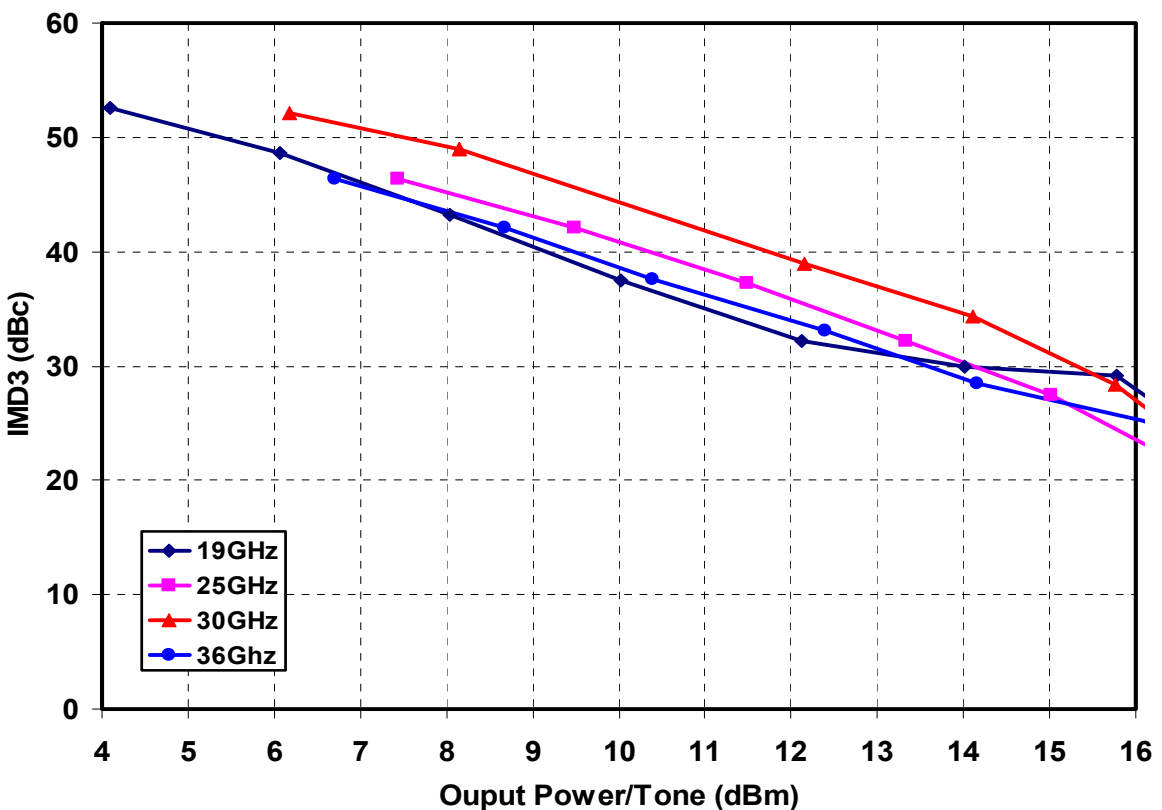
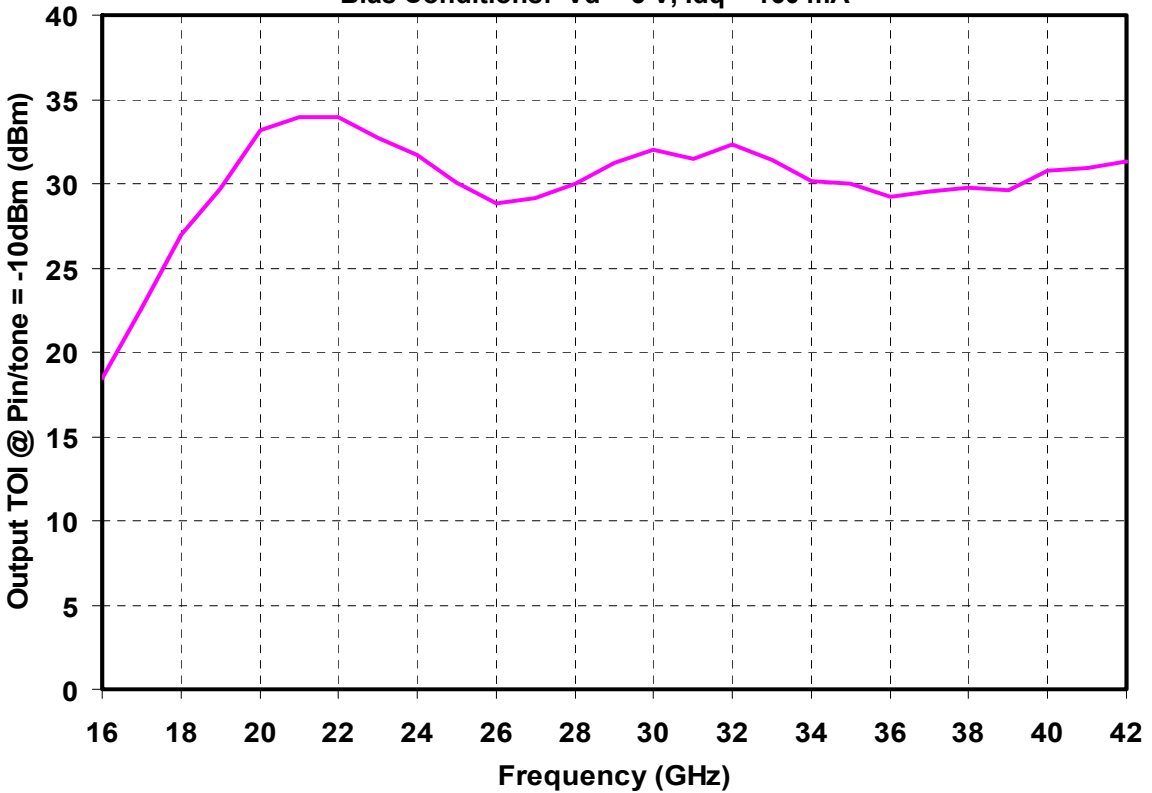
Preliminary Measured Data

Bias Conditions: $V_d = 5\text{ V}$, $I_{dq} = 160\text{ mA}$

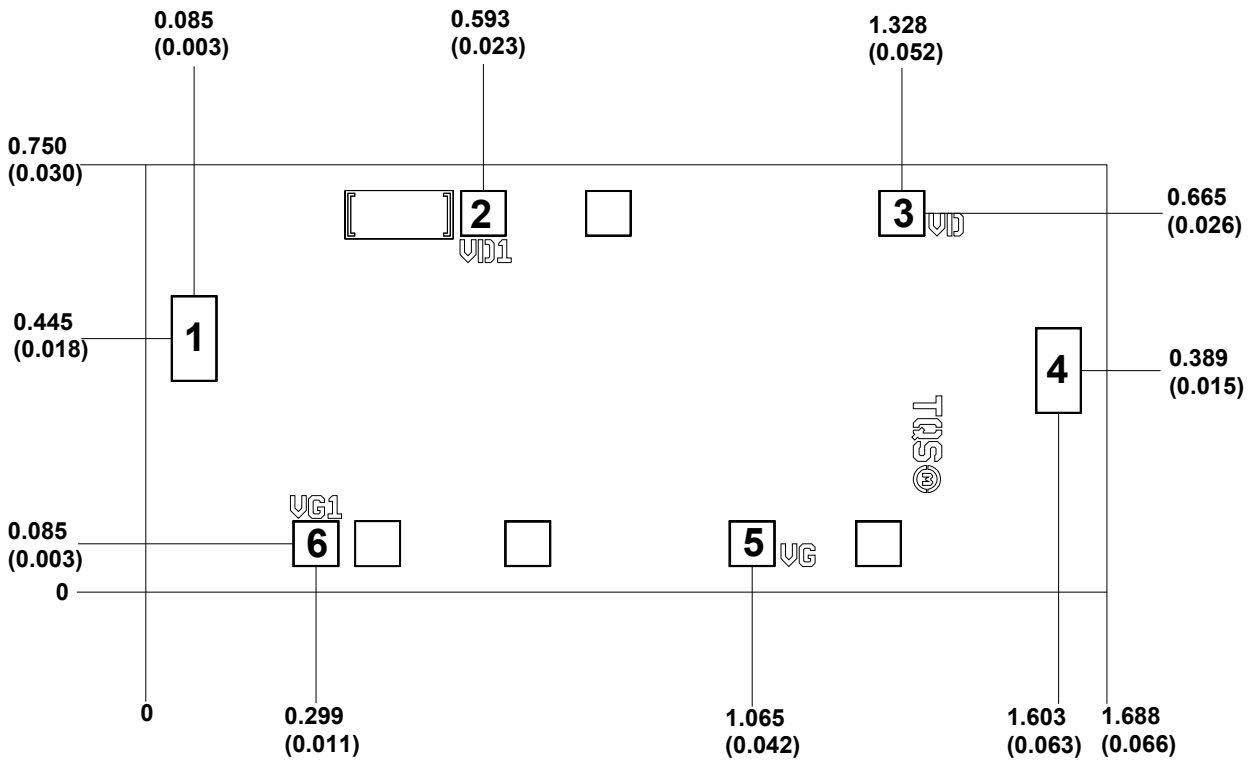


Preliminary Measured Data

Bias Conditions: $V_d = 5\text{ V}$, $I_{dq} = 160\text{ mA}$



Mechanical Drawing



Units: Millimeters (inches)

Thickness: 0.100 (0.004) (Reference Only)

Cip edge to bond pad dimensions are shown to center of bond pad

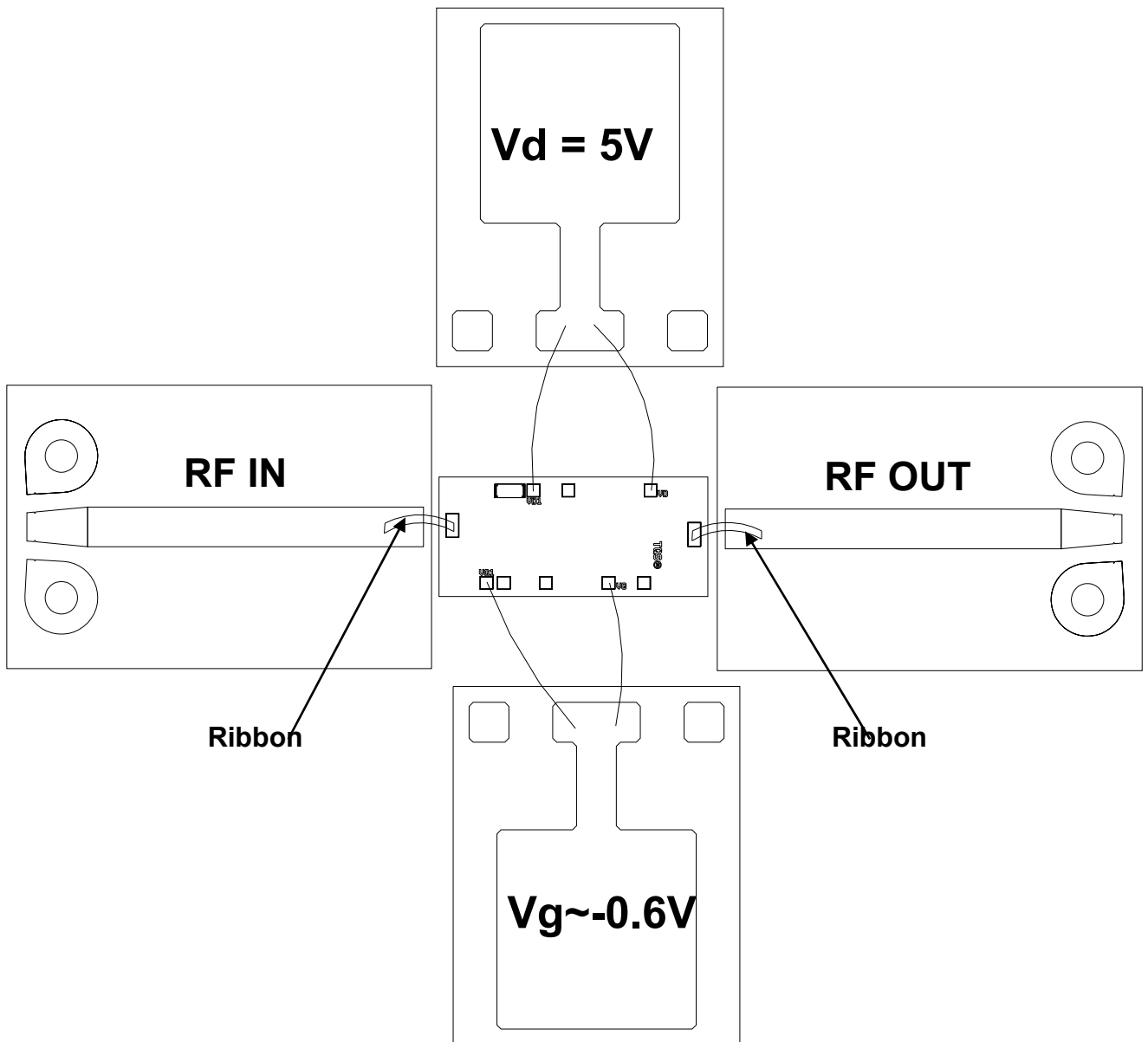
Chip size tolerance: +/- 0.051 (0.002)

RF Ground is backside of MMIC

Bond pad #1:	(RF In)	0.080 x 0.150 (0.003 x 0.006)
Bond pad #2, #3:	(Vd)	0.080 x 0.080 (0.003 x 0.003)
Bond pad #4:	(RF Out)	0.080 x 0.150 (0.003 x 0.006)
Bond pad #5, #6:	(Vg)	0.080 x 0.080 (0.003 x 0.003)

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.

Recommended Chip Assembly Diagram



Adjust V_g to get $I_d = 160mA$

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.

Assembly Process Notes

Reflow process assembly notes:

- Use AuSn (80/20) solder with limited exposure to temperatures at or above 300⁰C (30 seconds max).
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- No fluxes should be utilized.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.
- Microwave or radiant curing should not be used because of differential heating.
- Coefficient of thermal expansion matching is critical.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Maximum stage temperature is 200⁰C.

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.